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論文 / 著書情報 Article / Book Information

題目(和文)				
Title(English)	Thin Film Synthesis of Coordination-Compounds by Dry Process			
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学位種別(和文)	博士論文			
Category(English)	Doctoral Thesis			
種別(和文)	論文要旨			
Type(English)	Summary			

論 文 要 旨

THESIS SUMMARY

系・コース: Department of, Graduate major in	応用化学	系 コース	申請学位(専攻分野): Academic Degree Requested	博士 Doctor of	(工学)	
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要旨(和文 2000 字程度)

Thesis Summary (approx.2000 Japanese Characters)

This doctoral thesis entitled "Thin Film Synthesis of Coordination-Compounds by Dry Process" comprises five chapters. This work reports on a novel route to fabricate coordination-compound thin film by dry process.

In Chapter 1, the author reviews the coordination compounds focusing on the metal complex hydrides and metal–organic frameworks (MOFs). For thin film growth of the coordination compounds, the author explains the problem in conventional thermal evaporation for the materials with low decomposition temperature and claims the necessity of a new dry process. In this study, the author demonstrates the thin film synthesis of a calcium imide, CaNH using reactive magnetron sputtering, and MOF, $Cu_3(HHTP)_2$ (HHTP = 2,3,6,7,10,11-hexahydroxytriphenylene) using multilayer deposition followed by vapor-assisted annealing.

In Chapter 2, the author describes the experimental procedures employed in fabricating and characterizing thin films of CaNH and $Cu_3(HHTP)_2$. The details of each method, including the operating principles and measurement techniques, are thoroughly described.

In Chapter 3, the author fabricates epitaxial thin films of CaNH using reactive magnetron sputtering. Two phases in Ca–N–H system, namely Ca₂NH (ionic crystal) and CaNH (metal complex hydride), are selectively grown by controlling H₂ partial pressure (P_{H2}): CaNH at $P_{H2} > 0.04$ Pa and Ca₂NH at $P_{H2} < 0.04$ Pa. *In-situ* plasma emission spectroscopy suggests that the modification of Ca-metal target surface to CaH_x under high P_{H2} leads to the formation of CaNH phase. Notably, this study is the first report on the metal complex imide thin film, providing a novel strategy to form complex imide thin films.

In Chapter 4, the author demonstrates the fabrication of (001)-oriented Cu₃(HHTP)₂ thin films. The developed process is comprised of two steps: 1) multilayer deposition of Cu(OAc)₂ and HHTP precursors on Al₂O₃ (0001) by infrared pulsed laser deposition and 2) subsequent post-deposition annealing under pyridine and H₂O vapor in the air. The author finds the multilayer precursor film is successfully crystallized and (001)-oriented after the post-deposition annealing. In addition, the conductivity of the (001)-oriented thin film is 0.5 S cm⁻¹, comparable to the film reported by the wet process. This is the first report on fabricating Cu₃(HHTP)₂ thin films using the dry process.

In Chapter 5, the author summarizes and concludes this work and describes the guidelines for future research on thin films of coordination compounds based on the developed dry processes.

To sum up, this thesis demonstrates the fabrication of coordination-compounds thin films which have not been achieved by conventional dry processes based on thermal evaporation. The author deserves a Doctor of Engineering from the Tokyo Institute of Technology.

注意:論文要旨は、東工大リサーチリポジトリ(T2R2)にてインターネット公表されますので、公表可能な範囲の内容で作成してください。 Attention: Thesis Summary will be published on Tokyo Tech Research Repository Website (T2R2).

備考:論文要旨は、和文 2000 字と英文 300 語を1部ずつ提出するか、もしくは英文 800 語を1部提出してください。

Note : Thesis Summary should be submitted in either a copy of 2000 Japanese Characters and 300 Words (English) or 1copy of 800 Words (English).